Accepted Manuscript

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PII:	\$1383-5866(16)30848-6
DOI:	http://dx.doi.org/10.1016/j.seppur.2017.08.031
Reference:	SEPPUR 13973
To appear in:	Separation and Purification Technology
Received Date:	27 June 2016
Revised Date:	14 June 2017
Accepted Date:	10 August 2017



Please cite this article as: T. Wang, Q-Y. Wu, W-L. Wang, Z. Chen, B-T. Li, A. Li, Z-Y. Liu, H-Y. Hu, Self-sensitized photodegradation of benzisothiazolinone by low-pressure UV-C irradiation: Kinetics, mechanisms, and the effect of media, *Separation and Purification Technology* (2017), doi: http://dx.doi.org/10.1016/j.seppur.2017.08.031

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ACCEPTED MANUSCRIPT

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Ting Wang^{a, b}, Qian-Yuan Wu^{b*}, Wen-Long Wang^{a, b}, Zhuo Chen^b, Bing-Tian Li^{a, b}, Ang Li^{a, b}, Zi-Ye Liu^c, Hong-Ying Hu^{a, d*}

^a Environmental Simulation and Pollution Control State Key Joint Laboratory, and State Environmental Protection Key Laboratory of Microorganism Application and Risk Control (SMARC), School of Environment, Tsinghua University, Beijing 100084, PR China

^b Key Laboratory of Microorganism Application and Risk Control of Shenzhen, Graduate School at Shenzhen, Tsinghua University, Shenzhen 518055, PR China

^c Shenzhen Key Lab of Nano-Micro Material Research, School of Chemical Biology and Biotechnology, Shenzhen Graduate School of Peking University, Shenzhen, 518055, PR China

^d Shenzhen Environmental Science and New Energy Technology Engineering Laboratory, Tsinghua-Berkeley Shenzhen Institute, Shenzhen 518055, PR China
* Corresponding author. E-mail: <u>hyhu@tsinghua.edu.cn</u>, wuqianyuan@tsinghua.edu.cn

Highlights

- UVC irradiation could degrade BIT efficiently.
- Both direct photodegradation and indirect photodegradation via •OH contributed to BIT degradation
- The photodegradation of BIT was a pH-depended process.
- The photodegradation pathway of BIT was proposed

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